



Publisher's note

The Publisher is pleased to announce that Professor Sheng Hsiung Lin joins the editorial team of the *Journal of Hazardous Materials* from October 1, 2003.

Professor Lin is currently University Distinguished Professor of Environmental Technology in the Department of Chemical Engineering at Yuan Ze University, where he has also served as Vice President since 1997. His research interests are in the area of environmental pollution control and resources recovery, with current research focusing on treatment of high-tech industrial wastewater. Professor Lin is specifically interested in developing various techniques for dealing with wastewaters generated by semiconductor, DRAM, TFT-LCD and gallium arsenide (GaAs) chip manufacturing processes.

Having completed his doctorate at Kansas State University in 1974, Professor Lin taught at University of Melbourne in Australia and Polytechnic University in New York. He also spent nine years working for General Electric Company, MA, USA before returning to Taiwan in 1989. His research has been recognised by a NSC Distinguished Research Award and the General Electric Company Inventor Award. A prolific author, Professor Lin has authored or co-authored in excess of 200 articles in peer-reviewed journals. In addition to being a member of the AIChE and International Ozone and Water Associations, Professor Lin is member of Sigma Xi, Omega Chi Epsilon and Phi Kappa Upsilon.

We are pleased to welcome Professor Lin to the editorial team and wish him much success in this new position.

Authors are encouraged to submit articles to Professor Lin at the following address from 1 October 2003:

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